# **Supporting Information**

Coordination polymer derived NiS@g-C<sub>3</sub>N<sub>4</sub> composite photocatalyst for sulfur vacancy and photothermal effect synergistic enhanced H<sub>2</sub> production

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### **Experimental section**

#### Material and characterization

All chemicals were of reagent grade and used for synthesis without further purification. The structure of CP was characterized on a diffractometer at 293 K (AXS SMART APEX II CCD, Bruker). PXRD patterns were recorded on X-ray diffractometer with CuKR ( $\lambda$ =1.5418 Å) radiation (X'Pert Pro Super, Philips). The Fourier transform infrared (FTIR) spectra were recorded on a FTIR spectrometer (Nicolet 6700). The electron paramagnetic resonance (EPR) spectrum was monitored using a digital X-band spectrometer (EMX-220, Bruker). The morphology was observed on a transmission electron microscopy (TEM, JEOL, JEM-2100F). XPS was performed with MgK $\alpha$  radiation (1253.6 eV) as an excitation source (ESCALab MKII, Thermo Scientific, and Waltham, MA). N<sub>2</sub> sorption analysis was conducted using an ASAP 2020 instrument (Micromeritics, Norcross, GA), equipped with an automated surface area, at 77 K using Barrett-Emmett-Teller (BET) calculations for the surface area. Diffuse reflectance spectra (DRS) were recorded on a Shimadzu-2501PC spectrometer using BaSO<sub>4</sub> as a standard. Photoluminescence (PL) spectra were measured by using a FL-2T2 instrument (SPEX, USA) with 450-W xenon lamp monochromatized by double grating (1200 grmu<sup>-1</sup>). Electrochemical experiments were conducted on CHI 660E electrochemical workstation.

## Synthesis of CP, NCP and NiS@g-C<sub>3</sub>N<sub>4</sub>

**CP** was prepared from the mixture of Ni(OAc)·4H<sub>2</sub>O (0.025 g, 0.1 mmol), MPPI (0.031 g, 0.2 mmol) and 8 mL H<sub>2</sub>O. The pH value of this solution was adjusted to 5.0 with NaOH (1 mol·L<sup>-1</sup>). The mixture was stirred for 30 min, then transferred to a 25 mL Teflon-lined stainless steel bomb and kept at 150 °C under autogenously pressure for 120 h. The reaction system was cooled to room temperature during 24 h. A large

amount of green crystals was obtained. Yield: 82 % (based on Ni). The crystals of **CP** (0.6 g) were ground for 2.5 h with an agate mortar and pestle. Obtained powders were dissolved in methanol (20 mL) and placed in a Teflon autoclave, which were heated in a microwave oven at 300 W for 3 h. The resulted **NCP** were separated by centrifugation, rinsed with water, and dried in a vacuum drier at 80 °C for overnight. **NCP** were put in a tube furnace and heated at the rate of 2 °C·min<sup>-1</sup> to 500 °C under the protection Ar gas flow. The obtained results were collected, washed with water for several times, and then dried in a vacuum oven at 70 °C for 24 h. The product was named as **NiS@g-C<sub>3</sub>N<sub>4</sub>(A)**. The photocatalysts obtained at 550 and 600 °C were donated as **NiS@g-C<sub>3</sub>N<sub>4</sub>(B)** and **NiS@g-C<sub>3</sub>N<sub>4</sub>(C)**.

### *Electrochemical measurements*

To prepare the electrode, NiS@g-C<sub>3</sub>N<sub>4</sub> (10 mg) was dispersed into 3 mL ethanol to give homogeneous suspension upon bath sonication. The suspension (5  $\mu$ L) was dip-coated onto FTO and the electrode was dried at room temperature. Photoelectrochemical tests were carried out with a conventional three-electrode system in quartz cell filled with 0.5 M Na<sub>2</sub>SO<sub>4</sub> electrolyte (50 mL), with the NiS@g-C<sub>3</sub>N<sub>4</sub>/FTO electrode serving as the working electrode, a Pt plate as the counter electrode, and a saturated calomel electrode (SCE) as the reference electrode. A 300 W Xe lamp (Bejing Perfect Co. Ltd., PLS-SXE-300UV) with a cutoff filter ( $\lambda \ge$ 420 nm) was used as the excitation light source for visible irradiation. Electrochemical impedance spectra (EIS) were recorded in potentiostatic mode. The amplitude of sinusoidal wave was 10 mV, and the frequency of the sinusoidal wave ranged from 100 kHz to 0.01 Hz.

## Photocatalytic $H_2$ production

The photocatalytic reactions were conducted in a 100 mL quartz reactor at room

temperature and the visible light source is 8 cm away from this reactor. NiS@g-C<sub>3</sub>N<sub>4</sub> (20 mg) was dispersed in 60 mL lactic acid solution (10 %, as sacrificial agent) with stirring. At first, the system was deaerated by bubbling N<sub>2</sub> for 20 min, and then irradiated with above mentioned lamp equipped with a cut off filter ( $\lambda \ge 420$  nm). The generated H<sub>2</sub> were measured through the online gas chromatograph (GC 7900) equipped with a TCD detector. The apparent quantum yield (AQY) was measured using the same light source equipped with a monochromatic filter (450 nm). The photo flux of the light was determined with a radiometer (Photoelectric instrument factory of Beijing normal university). The apparent quantum yield was calculated using the following equation.

AQY (%) = (number of reacted electrons/number of incident photons)  $\times$  100% = (2  $\times$  number of evolved H<sub>2</sub> molecules/number of incident photons)  $\times$  100%

Table S1 the contents of different C in  $NiS@g-C_3N_4$ .

NiS@g-C <sub>3</sub> N <sub>4</sub>	Α	В	С
N-C=N (%)	82.6	90.3	71.9
C-C (%)	17.4	9.7	28.1

# Table S2 the contents of different N in NiS@g-C<sub>3</sub>N<sub>4</sub>.

NiS@g-C <sub>3</sub> N <sub>4</sub>	A	В	С
N-Ni (%)	12.3	8.4	0
C=N-C (%)	43.2	45.3	48.1
N-(C) <sub>3</sub> (%)	44.5	46.3	51.9

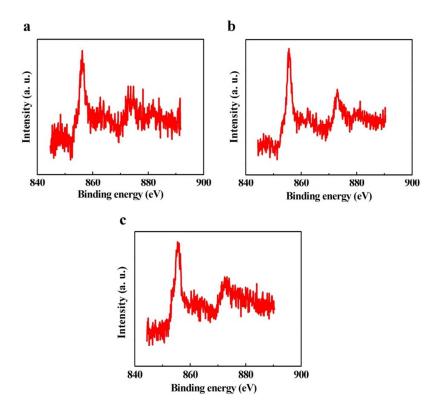


Figure S1 XPS spectra of Ni 2p, (a)  $NiS@g-C_3N_4(A)$ ; (b)  $NiS@g-C_3N_4(B)$ ; (c)

 $NiS@g-C_3N_4(C).$ 

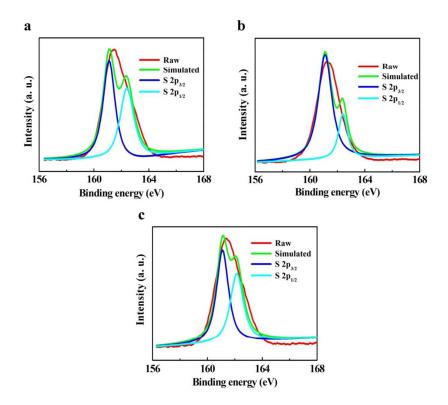


Figure S2 XPS spectra of S 2p, (a) NiS@g-C<sub>3</sub>N<sub>4</sub>(A); (b) NiS@g-C<sub>3</sub>N<sub>4</sub>(B); (c)

 $NiS@g-C_3N_4(C)$ 

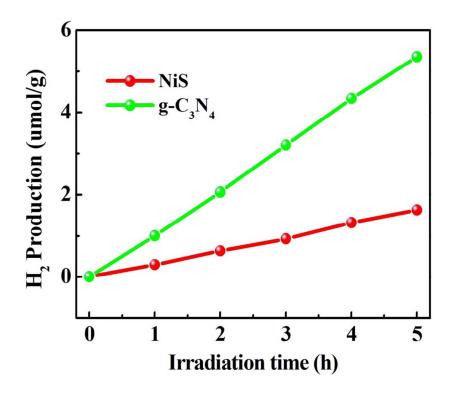


Figure S3 Time courses of H<sub>2</sub> production for NiS and g-C<sub>3</sub>N<sub>4</sub>